

2823#
IFU

PATENT
Customer No. 23494
Attorney Docket No. TI-25250
Application No.: 09/199,829

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of:)
SMITH et al.) Group Art Unit: 2823
Application No.: 09/199,829) Examiner: Julio J. MALDONADO
Filed: November 25, 1998)
For: HYDROGEN PLASMA)
PHOTORESIST STRIP AND)
POLYMERIC RESIDUE CLEANUP)
PROCESS FOR OXYGEN-)
SENSATIVE MATERIALS)

Assistant Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Sir:


PETITION FOR EXTENSION OF TIME

Applicant hereby petitions for a three month extension of time to reply to the
Office Action of May 4, 2004.

Please grant any extensions of time required to enter this response and charge
any additional required fees to the Texas Instruments Deposit Account 20-0668.

Respectfully submitted,

Dated: October 8, 2004

By: 
Jonathan A. Hack
Reg. No. 47,623

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